

10/552534

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Roberto Fenzi
Title : PUNCTURE RESISTANT TEXTILE STRUCTURE,
ESPECIALLY FOR SHOE SOLES
International
Application No. : PCT/IT2004/000208
International
Filing Date : April 14, 2004
Docket No. : 38853
Customer No. : 000116

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In accordance with 37 C.F.R. § 1.98, applicant is submitting herewith Form PTO-1449 listing references for consideration by the Examiner. Copies of the references are not included because they were previously sent by the International Bureau or are otherwise not required.

Respectfully submitted
PEARNE & GORDON LLP

By: John P. Murtaugh
John P. Murtaugh, Reg. No. 34226

1801 East 9th Street
Suite 1200
Cleveland, Ohio 44114-3108
(216) 579-1700

Date: 10-11-05

Form PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 38853	SERIAL NO.
INFORMATION DISCLOSURE CITATION BY APPLICANT (USE SEVERAL SHEETS IF NECESSARY)		APPLICANT: 10/552534 Roberto Fenzi	
		FILING DATE: herewith	GROUP ART UNIT:

U.S. PATENT DOCUMENTS

Examiner Initial		Document No.	Date	Name	Class	Subclass	Filing Date If Appropriate
/L.S./	A	5,480,706	01/1996	Li, et al.			
/L.S./	B	5,677,029	10/1997	Prevorsek, et al.			
/L.S./	C	5,880,042	03/1999	Schuster, et al.			
/L.S./	D	2003/180517	09/2003	Karall			
/L.S./	E	6,368,989	04/2002	Pascual, et al.			
	F						
	G						
	H						
	I						
	J						
	K						

FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Class	Subclass	Translation
/L.S./	L	WO 01/68361	09/2001	PCT			
/L.S./	M	WO 01/51263	07/2001	PCT			
	N						
	P						
	Q						

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	R	
	S	
	T	

Examiner: /Lynda Salvatore/

Date Considered 09/26/2007

*Examiner: Initial if reference considered, regardless of whether citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.